## APPENDIX B

The entire set of pending claims, including the "clean" version of the amended claims in this amendment, is as follows for the Examiner's convenience.

- 1. (Amended) A liquid crystal display, comprising:
- a substrate;
- a black matrix formed on the substrate;
- a plurality of color filters formed on the substrate, each color filter having a flat central portion and a peripheral portion placed on the black matrix and thinner than the flat central portion; and

a common electrode formed on the plurality of color filters.

- 2. (Amended) The liquid crystal display of claim 1, wherein the plurality of color filters comprise a first color filter and a second color filter neighboring and overlapping the first color filter over the black matrix.
- 3. (Amended) The liquid crystal display of claim 2, wherein the peripheral portion of the second color filter overlaps the peripheral portion of the first color filter.
- 4. (Amended) The liquid crystal display of claim 2, wherein the peripheral portion of the second color filter overlaps the peripheral portion and the central portion of the first color filter.

- 5. (Amended) The liquid crystal display of claim 1, wherein the plurality of color filters comprise a first color filter and a second color filter spaced apart from the first color filter with a predetermined distance therebetween.
- 6. (Amended) A method for fabricating a liquid crystal display, the method comprising the steps of:

forming a black matrix on a substrate;

sequentially forming a plurality of color filters on the substrate, each color filter having a flat central portion and a peripheral portion placed on the black matrix and thinner than the central portion; and

forming a common electrode on the plurality of color filters.

7. (Amended) The method of claim 6, wherein the step of sequentially forming the plurality of color filters comprises the steps of:

forming a color filter material over the substrate; and

patterning the color filter material by using a mask having a transparent pattern, a semitransparent pattern and an opaque pattern,

wherein the semitransparent pattern is used for forming the peripheral portion of each color filter.

8. (Amended) A liquid crystal display, comprising:

a substrate;

a plurality of gate lines formed on the substrate;

a plurality of data lines crossing over the gate lines;

a plurality of pixel regions defined by the plurality of gate lines and the plurality of data lines;

a thin film transistor formed at each pixel region;

a plurality of color filters, each color filter having a flat central portion and a peripheral portion placed on the data lines and thinner than the central portion;

a plurality of contact holes exposing the drain electrodes; and pixel electrodes connected to the drain electrodes through the contact holes.

- 9. (Amended) The liquid crystal display of claim 8, wherein the plurality of color filters comprise a first color filter and a second color filter neighboring and overlapping the first color filter over the data lines.
- 10. (Amended) The liquid crystal display of claim 9, wherein the peripheral portion of the second color filter overlaps the peripheral portion of the first color filter.
- 11. (Amended) The liquid crystal display of claim 10, wherein the peripheral portion of the second color filter overlaps the peripheral portion and the central portion of the first color filter.
- 12. (Amended) The liquid crystal display of claim 8, wherein the second color filter is spaced apart from the first color filter with a predetermined distance therebetween.

13. (Amended) A method for fabricating a liquid crystal display, the method comprising the steps of:

forming a plurality of gate lines on a substrate;

forming a plurality of data lines on the substrate, wherein the plurality of gate lines and the plurality of data lines define a plurality of pixel regions;

forming a thin film transistor in each pixel regions;

sequentially forming a plurality of color filters, each color filter having a flat central portion and a peripheral portion placed on the data lines and thinner than the central portion; forming a plurality of contact holes to expose drain electrodes of the thin film transistors;

forming a plurality of pixel electrodes connected to the drain electrodes through the contact holes.

14. (Amended) The method of claim 13, wherein the step of sequentially forming the plurality of color filters comprises the steps of:

forming a color filter material over the substrate; and

patterning the color filter material by using a mask having a transparent pattern, a semitransparent pattern and an opaque pattern,

wherein the semitransparent pattern is used for forming the peripheral portion of each color filter.

and